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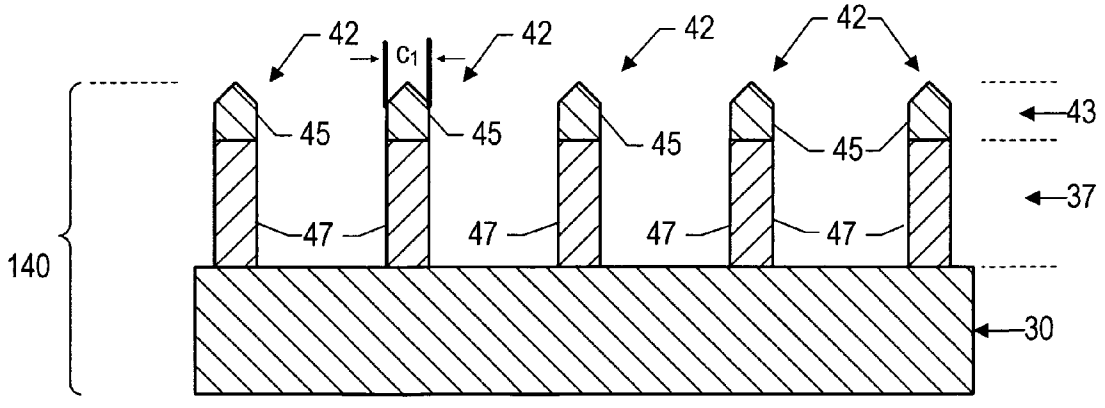
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(54) Title: METHOD OF FORMING A RECESSED STRUCTURE EMPLOYING A REVERSE TONE PROCESS



(57) Abstract: The present invention provides a method of forming recesses on a substrate, the method including forming on the substrate a patterning layer having first features; trim etching the first features to define trimmed features having a shape; and transferring an inverse of the shape into the substrate.

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